

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re:	Pascal Doppelt	Confirmation No.: 9143
Appl. No.:	10/529,569	Group Art Unit: 1621
Filed:	September 29, 2005	Examiner: Marialouisa Lao
For:	FLUORINE-FREE METALLIC COMPLEXES FOR GAS-PHASE CHEMICAL METAL DEPOSITION	

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

RESPONSE TO RESTRICTION REQUIREMENT

In response to the Office Action dated October 19, 2006, please amend this application as follows:

Amendments to the Claims are reflected in the listing of claims beginning on page 2 of this paper.

Remarks/Arguments and an election begin on page 6 of this paper.